

L Number	Hits	Search Text	DB	Time stamp
4	482	((silicon near (oxide dioxide)) (sio."sub.2")) and (SOI (silicon near on near insulator) (silicon-on-insulator)) and (@ad<20011102 @rlad<20011102) and ((reduc\$3 remov\$3 releas\$3) near2 heat)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/09 11:15